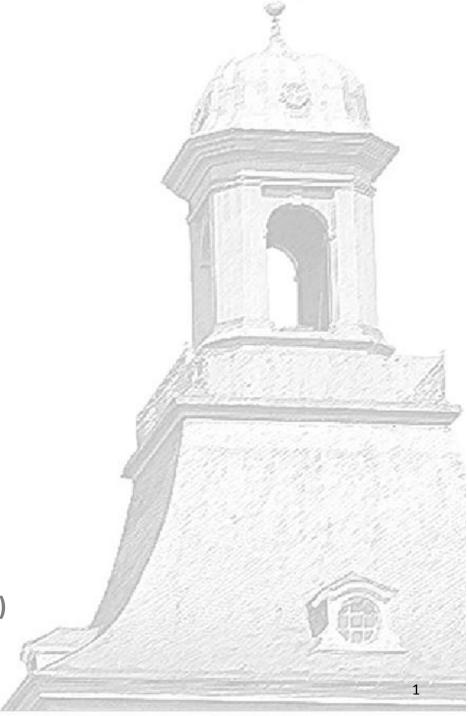
Bonn

AIDA 2020 Kick-off (Jun 4, 2015) Norbert Wermes (UBonn)



Current foci on new pixel R&D interesting for ATLAS ITK

- 65 nm IC design, RD53
- CMOS Pixel Sensors
- 3D integration and TSVs
- new module concepts
- high BW test systems
- serial powering
- Test beam infrastructure @ ELSA 3.5 GeV eaccelerator (Bonn)

Center for Detector Research Bonn



CMOS Sensor Developments

- Fully depleted MAPS based on high resistive substrate CMOS sensors → DMAPS
- Technology evaluation (started 2012)
 - DMAPS test chips implemented with 5 different CMOS technologies
- Applications
 - Low mass pixel vertex detectors
 - ATLAS hybrid pixel detectors with active CMOS sensors (CPIX Demonstrator)
 - ATLAS Fully Monolithic Pixel Sensors
 - Photon imaging (X-ray spectroscopy, X-FEL, etc)
- Funding established

Resources

- Scientists
 - H.Krüger, F.Hügging, L.Gonella, N.Wermes
- PhD Students
 - T.Hirono, T.Obermann, J.Janssen, D. Pohl
- 3 Master students
- 3+2 Chip designers
 - T. Hemperek, I. Kishishita, P. Rymaszewski + new
- 2 Technicians

contribution for WP6

- sensor design
 - so far (2013/2014) submitted
 - Tower Jazz (w/ Strasbourg)
 - Lfoundry (w/ CPPM, KIT)
 - ESPROS
 - XFAB
 - Toshiba
 - in preparation/planning
 - LF demonstrator (150 nm, w/ CPPM)
 - XFAB demonstrator (pending)
 - LF fully monolithic (w/ SLAC)
 - ESPROS 150 nm (tbd)
- sensor characterizations (in LAB and test beams)
 - currently characterized
 - AMS180 V2 & V4
 - LF
 - Toshiba
- TCAD simulations